		Application No.	Applicant(s)
		09/764,207	
		Examin r	LAY ET AL.
			Art Onit
		Mary Wilczewski	2822
1	The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.  1. A This communication is responsive to the amendment filed on February 05, 2004.		
2. 🖾 The allowed claim(s) is/are <u>1,3,4 and 6-10</u> .			
3	3. A The drawings filed on 19 January 2001 are accepted by the Examiner.		
<ul> <li>4. ☑ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a) ☑ All b) ☐ Some* c) ☐ None of the:</li> <li>1. ☑ Certified copies of the priority documents have been received.</li> <li>2. ☐ Certified copies of the priority documents have been received in Application No.</li> <li>3. ☐ Copies of the certified copies of the priority documents have been received in this national stage application from International Bureau (PCT Rule 17.2(a)).</li> </ul>			
			actional state when
			lational stage application from the
	* Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application.  5. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.  6. CORRECTED DRAWINGS ( as "replacement sheets") must be submitted.  (a) including changes required by the Nötice of Draftsperson's Patent Drawing Review (PTO-948) attached  1) hereto or 2) to Paper No./Mail Date  (b) including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date  Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of			
<b>7.</b> L	DEPOSIT OF and/or INFORMATION about the deposit of attached Examiner's comment regarding REQUIREMENT FOR		
Atta	ichm nt(s)		
1. K	Notice of References Cited (PTO-892)	5. Notice of Informal Pate	ent Application (PTO 450)
	Notice of Draftperson's Patent Drawing Review (PTO-948)	<ol> <li>Interview Summary (P</li> </ol>	TÓ-413)
	Information Disclosure Statements (PTO-1449 or PTO/SB/08), Paper No./Mail Date	Paper No./Mail Date _ 7. ⊠ Examiner's Amendmei	nt/Comment
(	Examiner's Comment Regarding Requirement for Deposit of Biological Material	8. ☑ Examiner's Statement 9. ☐ Other	of Reasons for Allowance
<del></del>	atent and Trademark Office	F	M. Wilczewski Primary Examiner Fech Center 2800

3. 4. Application/Control Number: 09/764,207

Art Unit: 2822

## **EXAMINER'S AMENDMENT**

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

The application has been amended as follows:

This application is in condition for allowance except for the presence of claims 11-19 drawn to an invention non-elected without traverse. Accordingly, claims 11-19 have been cancelled.

## REASONS FOR ALLOWANCE

The following is an examiner's statement of reasons for allowance: It is well known in the art to form an insulating layer on the sidewalls of a bump electrode to prevent an electrical short through the side surface of the electrode which occurs due to a conductive elements or balls in ACA/ACF thereby yielding a plurality of metal bumps having sidewalls covered with an insulating layer, see, for example, Kim, U.S. Patent 6,232,563, of record or Chun, U.S. Patent 5,923,080, newly cited. However, Chun teaches to form the insulating layer on the entire outer surface of the electrode (see Figure 3; column 2, lines 59-61; and column 2, line 66, bridging column 3 to line 8). Kim et al. teach to form the insulating layer only on the side surfaces of each bump electrode (see column 3, lines 55-67; column 4, lines 47-62; column 4, line 66, bridging column 5 to line 32; and figures 4, 5B-5D and 6A-6B). Hence the structures of both Kim and

Application/Control Number: 09/764,207

Art Unit: 2822

Page 3

Chun comprise a plurality of metal bumps in which adjacent sidewalls of the bumps are covered with an insulating layer. None of the prior art of record teaches or suggests a structure comprising a plurality of metal bumps wherein the sidewall of a first bump is covered with an insulating layer but the adjacent sidewall of a second bump is not covered by an insulating layer, as presently claimed.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication should be directed to M. Wilczewski at telephone number (571) 272-1849.

M. Wilczewski Primary Examiner Tech Center 2800